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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No. : 10/753,406 Confirmation No. : 6394
First Named Inventor : Masayuki KOBAYASHI
Filed : January 9, 2004
TC/A.U. : 2812
Examiner : Jennifer M. Dolan
Docket No. : 056203.53141US
Customer No. : 23911
Title : Working Method of Metal Material and
Semiconductor Apparatus Fabricated by The
Method

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated September 6, 2005, Applicants provisionally elect with traverse Group II, Claims 5-11, drawn to a semiconductor device package, classified in class 257, subclass 676.

This election is made with traverse, it being submitted that the subject matter of the other group of claims is such that they should properly be examined and allowed in a single application.

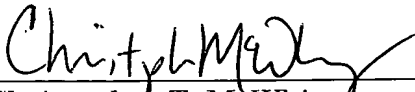
If there are any questions regarding this amendment or the application in general, a telephone call to the undersigned would be appreciated since this should expedite the prosecution of the application for all concerned.

If necessary to effect a timely response, this paper should be considered as a petition for an Extension of Time sufficient to effect a timely response, and

please charge any deficiency in fees or credit any overpayments to Deposit
Account No. 05-1323 (Docket # 056203.53141US).

Respectfully submitted,

October 3, 2005



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